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Substitute for form 1449A/PTO				Application Number	10/721,631		
INFORMATION DISCLOSURE				Filing Date	11/25/2003		
				First Named Inventor	Blauvelt et al.		
STATEMENT BY APPLICANT			ANT	Art Unit	2874		
	(Use as many sheets as necessary)			Examiner Name	John D Lee		
Sheet	1	of	2	Attorney Docket Number	XPNT31NP		

U.S. PATENT DOCUMENTS						
Examiner	Cite	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevan	
Initials*	No.3	Number - Kind Code ^{2 (# known)}			Figures Appear	
	ł	US- 2004-0052480 A1	03-18-2004	Benzoni et al		
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Examiner Initials*		Foreign Patent Document	Publication Date MM- DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
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Substitute for form 1449B/PTO				Complete if Known		
002000				Application Number	10/721,631	
INF	ORMATION DISC	a osi	IRF	Filing Date	11/25/2003	
STATEMENT BY APPLICANT				First Named Inventor	Blauvelt et al.	
STATE WIENT BY APPLICANT			- 14 1	Art Unit	2874	
	(Use as many sheets as necessary)			Examiner Name	John D Lee	
Sheet	2	of	2	Attorney Docket Number	XPNT31NP	

	NON PATENT LITERATURE DOCUMENTS	
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	BAZYLENKO ET AL, Fabrication of Light-Turning Mirrors in Buried-Channel silica Waveguides for Monolithic and Hybrid Integration, Journal of Lightwave Technology, 01/1997, Page(s) 148-153, Volume 15, Number 1	
	BOUADMA ET AL, 1.3-um GalnAsP/InP Buried-Ridge-Structure Laser and its Monolithic Integration with Photodetector Using RI Beam Etching, Journal of Lightwave Technology, 05/1994, Page(s) 742-748, Volume 12, Number 5	
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	JONES ET AL, Hybrid integration onto silicon motherboards with planar silica waveguides, IEE Proc. Optoelectron., 10/1996, Page(s) 316-321, Volume 143, Number 5	
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